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Wen-Ze Qiu, Hao-Cheng Yang, Zhi-Kang Xu

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Dopamine-assisted co-deposition: an emerging and promising strategy for

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Wen-Ze Qiu, Hao-Cheng Yang, Zhi-Kang Xu*

MOE Key Laboratory of Macromolecular Synthesis and Functionalization, Department of Polymer Science and Engineering, Zhejiang University, Hangzhou, 310027, China.

* Corresponding author. E-mail: <u>xuzk@zju.edu.cn</u>; fax: + 86 571 8795 1773.

1

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